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THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Patricia B. Smith, et al.

Docket No: TI-25250

Serial No: 09/199,829

Conf. No: 4119

Examiner: Julio J. Maldonado

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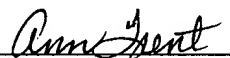
For: HYDROGEN PLASMA PHOTORESIST STRIP AND POLYMERIC RESIDUE
CLEANUP PROCESS FOR OXYGEN-SENSITIVE MATERIALS

AMENDMENT UNDER 37 C.F.R. § 1.111

Commissioner For Patents
P.O. Box 1450
Alexandria, VA 22313-1450

MAILING CERTIFICATE UNDER 37 C.F.R. §1.8(a)

I hereby certify that the above correspondence is being deposited with the U.S. Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on 3-22-05.


Ann Trent

Dear Sir:

Responsive to the Office Action mailed December 22, 2004, in connection with the above identified application, Applicants respectfully submit the following amendments and remarks.